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REISSUE PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Satoshi INOUE et al.

Group Art Unit: 2812

Application No.: 10/748,206

Examiner: R. BOOTH

Filed: December 31, 2003

Docket No.: 040852.98

For: MANUFACTURING METHOD OF ACTIVE MATRIX SUBSTRATE , ACTIVE MATRIX SUBSTRATE AND LIQUID CRYSTAL DISPLAY DEVICE

AMENDMENT UNDER 37 C.F.R. §1.173 IN REISSUE APPLICATION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the February 7, 2007 Office Action, and in consideration of the April 17, 2007 telephone interview with the Examiner, please amend this application as follows:

IN THE CLAIMS

55. (Amended) A device comprising:

a substrate;

an adherent layer formed over the substrate;

a thin film device being attached to the substrate by the adherent layer;

at least one of an insulation film, which is positioned over the thin film device

with respect to the adherent layer, and an intermediate layer, which is positioned between the

thin film device and the adherent layer, the one of the insulation film and the intermediate

layer having an opening where no thin film device is formed; and